

Resource Summary Report

Generated by RRID on Aug 5, 2026

Oxford: FlexAL ALD System Plasma Technology

RRID:SCR_020352

Type: Tool

Proper Citation

Oxford: FlexAL ALD System Plasma Technology (RRID:SCR_020352)

Resource Information

URL: <https://plasma.oxinst.com/products/ald/flexal>

Proper Citation: Oxford: FlexAL ALD System Plasma Technology (RRID:SCR_020352)

Description: FlexAL systems provide newrange of flexibility and capability in engineering of nanoscale structures and devices by offering remote plasma atomic layer deposition processes and thermal ALD within single ALD systems.

Resource Type: instrument resource

Keywords: Oxford, Plasma Tehnology, Instrument, Resource equipment, Equipment, USEdit,

Availability: Commercially available

Resource Name: Oxford: FlexAL ALD System Plasma Technology

Resource ID: SCR_020352

Alternate IDs: Model_Number_FlexAL

Record Creation Time: 20220129T080349+0000

Record Last Update: 20260801T190645+0000

Ratings and Alerts

No rating or validation information has been found for Oxford: FlexAL ALD System Plasma Technology.

No alerts have been found for Oxford: FlexAL ALD System Plasma Technology.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We have not found any literature mentions for this resource.